

Docket No.: M4065.0609/P609-D
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Jiutao Li

Application No.: NEW

Art Unit: N/A

Filed: January 16, 2004

Examiner: Not Yet Assigned

For: AGGLOMERATION ELIMINATION FOR
METAL SPUTTER DEPOSITION OF
CHALCOGENIDES

PRELIMINARY AMENDMENT

MS Patent Application
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

INTRODUCTORY COMMENTS

Prior to examination on the merits, please amend the above-identified U.S. patent application as follows:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims which begins on page 3 of this paper.

Remarks/Arguments begin on page 5 of this paper.